PATENT H1920/AMDP999US

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Date: June 2, 2006 /Christina M. Padamonsky/
Christina M. Padamonsky

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In repatent application of:

Applicant(s): Bhanwar Singh, et al. Examiner: John S. Ruggles

Serial No: 10/768,515 Art Unit: 1756

Filing Date: January 30, 2004

Title: DIELECTRIC PATTERN FORMATION FOR ORGANIC ELECTRONIC DEVICES

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

REPLY TO RESTRICTION REQUIREMENT DATED MAY 30, 2006

This Reply is in response to the Restriction Requirement mailed on May 30, 2006 in connection with the above-identified patent application.

The Examiner requires restriction to one of the following two groups of claims:

Group I – Claims 1-8, drawn to a mask having a translucent substrate and threedimensional feature(s) with absorbing material on vertical sidewall(s) (product), classified in class 430, subclass 5; and Group II – Claims 9-23, drawn to a method of making a patterned mask by producing feature(s) having vertical sidewall(s) on a translucent substrate, depositing absorbing material on the substrate, and removing absorbing material from all portions of the substrate except for the vertical sidewall(s) (claims 9-19, classified in class 430, subclass 5); and a method of nanoprint lithography that further includes close proximity (near field) exposure of a resist through the translucent substrate, and removing unexposed areas of the resist (claims 20-23, classified in class 430, subclass 311).

Applicants' representative hereby elects with traverse Group I (Claims 1-8, drawn to a mask having a translucent substrate and three-dimensional feature(s) with absorbing material on vertical sidewall(s) (product), classified in class 430, subclass 5) for further prosecution on the merits.

Should there be any questions regarding this paper, the Examiner is invited to contact applicants' undersigned representative at the telephone number below.

In the event any fees are due in connection with submission of this document, the Commissioner is authorized to charge such fees to Deposit Account No. 50-1063 [AMDP999US].

Respectfully submitted,

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